REMARKS

The Applicants respectfully request reconsideration of this application in view of

the above amendments and the following remarks.

35 U.S.C. §103(a) Rejection – Takemura and Sun

The Examiner has rejected claims 1-5, 7 and 10-14 under 35 U.S.C. §103(a) as

being unpatentable over U.S. Patent No. 5,759,739 issued to Takemura et al. (hereinafter

referred to as "Takemura") in view of U.S. Patent Application Publication No.

2005/0074699 issued to Sun et al. (hereinafter "Sun"). The Applicants respectfully

submit that the present claims are allowable over any combination of Takemura and Sun.

Claim 1 recites a method comprising:

"depositing a film layer on a substrate;

depositing a non-chemically amplified photoresist layer upon the film layer, the non-

chemically amplified photoresist having a developer-soluble resin component and a

photoactive compound component, the photoactive compound inhibiting the solubility of

the developer-soluble resin;

exposing selected portions of the non-chemically amplified photoresist layer to a light

source such that a solubility of the selected portions of the non-chemically amplified

photoresist layer is promoted; and

developing the exposed portions of the non-chemically amplified photoresist layer".

Accordingly, claim 1 pertains to a method of using a particular non-chemically

amplified photoresist. The particular non-chemically amplified photoresist has a

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developer-soluble resin component and a photoactive compound component, the

photoactive compound inhibits the solubility of the developer-soluble resin, and the

exposure promotes solubility of the non-chemically amplified photoresist.

The Examiner has admitted that <u>Takemura</u> does not disclose that the photoresist

layer is non-chemically amplified. See e.g., page 3 of the Office Action mailed on

5/11/06.

The Examiner has stated "Sun, in [0039] discloses that the chemically amplified

photresist layer can be replaced with a non-chemically amplified photoresist layer". See

e.g., page 3 of the Office Action mailed on 5/11/06. Paragraph [0039] in Sun discusses in

part "due to the extraordinarily thin photoresist, this invention opens an opportunity to

replace the ever troubling chemically amplified photoresist with non-chemically

amplified photoresists for the photolithography process of KrF or shorter wavelengths."

This paragraph [0039], as well as other portions of Sun, absolutely do not teach or

suggest the particular non-chemically amplified photoresist recited in claim 1.

The Examiner is reminded that to establish a prima facie case of obviousness, the

prior art reference (or references when combined) must teach or suggest all the claim

limitations.

Accordingly, claim 1 and its dependent claims are believed to be allowable over

Takemura and Sun, which combination is not admitted to be appropriate.

Independent claim 10 and its dependent claims are believed to be allowable for

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one or more similar reasons.

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35 U.S.C. §103(a) Rejection - Cathey and Sun

The Examiner has rejected claims 1, 6-7, 10 and 15 under 35 U.S.C. §103(a) as

being unpatentable over U.S. Patent No. 5,358,599 issued to Catheyet al. (hereinafter

referred to as "Cathey") in view of Sun. The Applicants respectfully submit that the

present claims are allowable over any combination of Cathey and Sun.

The Examiner has admitted that Cathey does not disclose that the photoresist

layer is non-chemically amplified. See e.g., page 4 of the Office Action mailed on

5/11/06.

As before, the Examiner has stated "Sun, in [0039] discloses that the chemically

amplified photresist layer can be replaced with a non-chemically amplified photoresist

layer". See e.g., page 3 of the Office Action mailed on 5/11/06. However, Sun

absolutely do not teach or suggest the particular non-chemically amplified photoresist

recited in independent claims 1 and 10. The discussion above is pertinent to this point.

Accordingly, independent claims 1 and 10, and their respective dependent claims,

are believed to be allowable over Cathey and Sun, which combination is not admitted to

be appropriate.

35 U.S.C. §103(a) Rejection – Cathey, Sun and Zang

The Examiner has rejected claims 8 and 9 under 35 U.S.C. §103(a) as being

unpatentable over Cathey in view of Sun as applied to claims 1, 6-7, 10 and 15, above,

and further in view of U. S. Patent Application Publication No. 2004/0204328 issued to

Zhang etl. (hereinafter "Zhang"). The Applicants respectfully submit that the present

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claims are allowable over any combination of Cathey, Sun and Zhang.

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As discussed above, Cathey and Sun do not teach or suggest the limitations of the

independent claims. Zhang does not remedy what is missing from Cathey and Sun.

Accordingly, the independent claims, and their respective dependent claims, are believed

to be allowable over Cathey, Sun, and Zhang, which combination is not admitted to be

appropriate.

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Conclusion

In view of the foregoing, it is believed that all claims now pending patentably

define the subject invention over the prior art of record and are in condition for

allowance. Applicants respectfully request that the rejections be withdrawn and the

claims be allowed at the earliest possible date.

Request For Telephone Interview

The Examiner is invited to call Brent E. Vecchia at (303) 740-1980 if there

remains any issue with allowance of the case.

Request For An Extension Of Time

The Applicants respectfully petition for an extension of time to respond to the

outstanding Office Action pursuant to 37 C.F.R. § 1.136(a) should one be necessary.

Please charge our Deposit Account No. 02-2666 to cover the necessary fee under 37

C.F.R. § 1.17 for such an extension.

Charge Our Deposit Account

Please charge any shortage to our Deposit Account No. 02-2666.

Respectfully submitted,

BLAKELY, SOKOLOFF, TAYLOR & ZAFMAN LLP

Date: 8/10/06

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